

ALD 2022 - AVS 22nd International Conference on Atomic Layer Deposition

Veranstaltung - ALD 2022 - AVS 22nd International Conference on Atomic Layer Deposition

Titel	ALD 2022 - AVS 22nd International Conference on Atomic Layer Deposition
Wann	So, 26. Juni 2022 - Mi, 29. Juni 2022

Beschreibung

ALD 2022 - AVS 22nd International Conference on Atomic Layer Deposition

The **AVS 22nd International Conference on Atomic Layer Deposition (ALD 2022)** featuring the **9th International Atomic Layer Etching Workshop (ALE 2022)** will be a three-day meeting dedicated to the science and technology of atomic layer controlled deposition of thin films and now topics related to atomic layer etching.

This year, the ALD conference will again incorporate the **Atomic Layer Etching 2022 Workshop (ALE 2022)**.

The conference will take place **Sunday, June 26-Wednesday, June 29, 2022**, at the International Convention Center (ICC) Ghent in Ghent, Belgium.

Learn more about this event by following Link:

<https://ald2022.avs.org/>

Lokalität - Ghent

Standort	Ghent
Ortsname	Ghent
Land	BE